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	<u>9/7/2004</u> .		
3. The drawings filed on 28 August 2003 are accepted by the Examine			
<ul> <li>4. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.</li> <li>a) ☐ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☐ Certified copies of the priority documents have been reconstructed.</li> <li>2. ☐ Certified copies of the priority documents have been reconstructed.</li> <li>3. ☐ Copies of the certified copies of the priority documents have been reconstructed.</li> </ul>	eived.	 national stage applicat	ion from the
International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this comnoted below. Failure to timely comply will result in ABANDONMENT of this THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	munication to file a reply of a polication.	complying with the req	uirements
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be submitted. Note INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s</li> </ol>	the attached EXAMINER' ) why the oath or declarat	S AMENDMENT or NO	TICE OF
6.  CORRECTED DRAWINGS ( as "replacement sheets") must be submi	Ited		
<ul><li>(a) ☐ including changes required by the Notice of Draftsperson's Paten</li></ul>	t Drawing Review ( PTO-9	948) attached	
1) in hereto or 2) ito Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendme Paper No./Mail Date	ent / Comment or in the Of	ffice action of	
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be labeled as such in the header a	ld be written on the drawing	gs in the front (not the b	ack) of
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOL attached Examiner's comment regarding REQUIREMENT FOR THE D	OCICAL MATERIAL		te the
Attachment(s) .  Notice of References Cited (PTO-892) .  Notice of Draftperson's Patent Drawing Review (PTO-948)	. ☐ Notice of Informal Pa	itent Application (PTO-	152)
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## **EXAMINER'S AMENDMENT / ALLOWANCE**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Richard Fichter on 10/29/2004.

The application has been amended as follows:

## In the claims:

In Claim 6, line 4, the phrase, "cycohexyl methacrylate" has been replaced with the phrase, --cyclohexyl methacrylate--.

In Claim 6, line 4, the word, "brnyl" has been replaced with the word, --bornyl--.

## Allowable Subject Matter

The formal drawings (6 sheets, 6 figures) filed by the applicant on 8/28/2003 are acknowledged and approved by the examiner. The substitute declaration filed by the applicant on 9/7/2004 is approved by the examiner. The objections to the specification, including the abstract of the disclosure, set forth in paragraphs 4-5 of the previous

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Office Action (i.e., the *Ex parte Quayle* action mailed on 7/12/2004), are withdrawn in light of the applicant's amendments to correct various informalities. The objections to Claims 1 and 10, set forth in paragraph 6 of the previous Office Action, are withdrawn in light of the applicant's amendments to correct various typographical errors.

Claims 1 – 11 are allowed. The following is an examiner's statement of reasons for allowance: The claimed process, as represented by independent Claim 1 (from which Claims 2 –11 depend), is drawn to preparing an optical waveguide from an acrylate / titanium alkoxide composite material. The process comprises forming a specific precursor solution by reacting an <a href="acrylate">acrylate</a> with <a href="titanium alkoxide">titanium alkoxide</a> in the presence of a <a href="silicon coupling agent">silicon coupling agent</a> and <a href="water by an <a href="acrid-free sol-gel">acid-free sol-gel</a> method, coating such solution on a silicon dioxide-coated silicon chip and evaporating the solvent at a specific temperature to form a composite film, using <a href="lithography to form a channel">lithography to form a channel</a> on the resulting film, repeating the step of forming the precursor solution while using a <a href="different ratio of acrylate and titanium alkoxide">different ratio of acrylate and titanium alkoxide</a> in order to form a solution having a refractive index less than that of the solution obtained from the step above, and applying the lower refractive index solution onto the film having the channel(s), evaporating the solvent, and then baking to produce the acrylate / titanium alkoxide composite optical waveguide component.

The closest prior art of record is discussed below. Dawes et al. (USPN 6,144,795) teaches a process of forming a hybrid organic-inorganic optical waveguide device but does not teach or reasonably suggest using the applicant's claimed precursor solution (e.g., the material of Dawes et al. lacks an acrylate component) or

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using lithography to form a channel in the deposited film. Kuramoto et al. (US 2003/0228120 A1) teaches a process of forming a hybrid organic-inorganic optical waveguide but does not teach or reasonably suggest using the applicant's claimed precursor solution (e.g., the material of Kuramoto et al. lacks a silicon coupling agent) or process (e.g., using lithography to form a channel on the resulting film, and repeating the step of forming the precursor solution while using a different ratio of acrylate and titanium alkoxide in order to form a solution having a refractive index less than that of the solution obtained from the first step, and applying the lower refractive index solution onto the film having the channel(s)). Etienne (US 2004/0071426 A1) teaches forming a hybrid organic-inorganic waveguide but lacks a teaching of the claimed precursor composition (e.g., a titanium alkoxide) or method (e.g., forming a channel using lithography, repeating the deposition with a precursor solution that has a different ratio of acrylate and titanium alkoxide, etc.). The organic / inorganic hybrid composition taught by Su et al. (USPN 6,492,540 B1) does not contain a silicon coupling agent, and there is no teaching or suggestion in Su et al. to perform the applicant's claimed process steps. The metal alkoxide polymers taught by Zha (US 2003/0195321 A1) are formed by acidolysis (i.e., not an acid-free sol-gel method), and Zha does not teach the claimed process steps (e.g., repeating the deposition with a precursor solution that has a different ratio of acrylate and titanium alkoxide). The organic-inorganic composite material of Kuramoto et al.(2) (US 2003/0165710 A1) is different from the applicant's claimed precursor solution and is not formed by an acid-free sol-gel method. Further, Kuramoto et al.(2) does not teach or reasonably suggest forming a channel using

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lithography in the context of the applicant's claims. Rantala (US 2004/0008960 A1) teaches forming an organic-inorganic hybrid material optical waveguide by depositing the hybrid material onto a substrate, patterning the deposited material (i.e., forming channels) to form a core, and then depositing a hybrid material having a different ratio of components over the previously patterned film to form a cladding. However, the precursor material taught by Rantala is significantly different from the applicant's claimed precursor solution (i.e., a solution prepared by reacting an acrylate with titanium alkoxide in the presence of a silicon coupling agent and water by an acid-free sol-gel method), and there is no teaching or suggestion in the prior art to use a precursor solution prepared in the manner claimed by the applicant in the process of Rantala. The photo-patternable perfluorinated silane sol-gel material taught by Fardad et al. (US 2004/0033309 A1) is different from the applicant's claimed precursor solution, and the process of Fardad et al. does not include repeating the deposition with a precursor solution that has a different ratio of components such as acrylate and titanium alkoxide. The composition used to produce the waveguide tunable laser of Reisfeld et al. (USPN 5,783,319) does not contain a silicon coupling agent and is not prepared by an acid-free sol-gel method. Additionally, the process used by Reisfeld et al. to produce the waveguide tunable laser is significantly different from the applicant's claimed process (e.g., there are no channel forming or repeating steps in the process of Reisfeld et al.). As such, the prior art of record, alone or in combination, does not teach or reasonably suggest each and every limitation of independent Claim 1, and this claim is allowed. Since Claims 2 – 11 depend from Claim 1, these claims are also allowed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wesley D Markham whose telephone number is (571) 272-1422. The examiner can normally be reached on Monday - Friday, 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive Beck can be reached on (571) 272-1415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

V∭∕∕ WDM

SYMBE P. BECK PERVISORY PATENT EXAMINES THE STATE OF THE 1760 Wesley D Markham Examiner Art Unit 1762